

THERMAL EVAPORATION SYSTEM



Intended Use of the Instrument: Vapor Phase Deposition of Organic and Inorganic Materials in Optoelectronic Device Fabrication

Instrument Brand/Model: Nanovak NVHT350

AGU CRF Thematic Laboratory: Optoelectronic Device Laboratory

Location of the Instrument: AGU-CRF LAB5

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High vacuum thermal evaporation system is used to deposit thin metal films of air-stable materials.